Approved,

PATENT
7/10/06

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Serial No.:

10/797,425

Applicant:

Pradip K. Roy et al.

Art Unit:

2811

Title:

SILICON-GERMANIUM THIN LAYER SEMICONDUCTOR

STRUCTURE WITH VARIABLE SILICON-GERMANIUM

COMPOSITION AND METHOD OF FABRICATION

Attorney Docket:

TPS-008

Confirmation No.:

4397

Cincinnati, OH

June 6, 2006

Mail Stop AF Commissioner for Patents P.O. Box 1450 Alexandria, VA 22313-1450

Sir:

RESPONSE TO FINAL OFFICE ACTION

This paper is responsive to the final Office Action mailed April 6, 2006. The Examiner has indicated that claims 1-29 and 54-57 are pending in the application, claims 1-3, 5, 8, 11-14, 25-57 and 54-57 are rejected and claims 4, 6, 7, 9, 10, 15-24, 28 and 29 are withdrawn from consideration. The following amendments and remarks are respectfully submitted.

Amendments to the Specification:

None

Amendments to the Claims:

Pages 2-9

Amendments to the Abstract:

None

Amendments to the Drawings:

None

Remarks:

Pages 10-15

Attachments:

None